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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/534,035	05/06/2005	Shing-Tung Yau	050106	9738	
44920 Venable LLP				EXAMINER	
Raymond J. Ho		KIM, CHONG R			
575 7th Street NW Washington, DC 20004-1601			ART UNIT	PAPER NUMBER	
			2624		
			MAIL DATE	DELIVERY MODE	
			10/14/2008	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
	10/534,035	YAU ET AL.			
Office Action Summary	Examiner	Art Unit			
	CHARLES KIM	2624			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period was period for reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim vill apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONEI	lely filed the mailing date of this communication. (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 18 Au	action is non-final. nce except for formal matters, pro				
Disposition of Claims					
4) Claim(s) 134-159 is/are pending in the applicate 4a) Of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 134-159 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or Application Papers 9) The specification is objected to by the Examine	vn from consideration. r election requirement. r.	ov the Eveniner			
10)☑ The drawing(s) filed on <u>06 May 2005</u> is/are: a)☑ accepted or b)☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11)☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 4/21/08.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ite			

Application/Control Number: 10/534,035 Page 2

Art Unit: 2624

DETAILED ACTION

Requirement for Information

1. Applicant and the assignee of this application are required under 37 CFR 1.105 to provide the following information that the examiner has determined is reasonably necessary to the examination of this application.

In response to this requirement, please provide copies of each publication which any of the applicants authored or co-authored and which describe the disclosed subject matter of conformal mapping comprising either the steps of forming a doubling mesh or determining a holomorphic 1-form basis of a mesh representation.

In addition, please provide the title, citation and copy of each publication that any of the applicants relied upon to develop the disclosed subject matter that describes the applicant's invention, particularly as to developing the steps of forming a doubling mesh and the steps of determining a holomorphic 1-form basis of a mesh representation. For each publication, please provide a concise explanation of the reliance placed on that publication in the development of the disclosed subject matter.

Claim Rejections - 35 USC § 101

35 U.S.C. 101 reads as follows:

Whoever invents or discovers any new and useful process, machine, manufacture, or composition of matter, or any new and useful improvement thereof, may obtain a patent therefor, subject to the conditions and requirements of this title.

2. Claim(s) 134-159 is/are rejected under 35 U.S.C. 101 as not falling within one of the four statutory categories of invention. While the claims recite a series of steps or acts to be

performed, a statutory "process" under 35 U.S.C. 101 must (1) be tied to another statutory category (such as a manufacture or machine), or (2) transform underlying subject matter (such as an article or material) to a different state or thing (Reference the May 15, 2008 memorandum issued by Deputy Commissioner for Patent Examining Policy, John J. Love, titled "Clarification of 'Processes' under 35 U.S.C. 101")¹. The instant claims neither transform underlying subject matter nor positively recite structure associated with another statutory category, and therefore do not define a statutory process.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

- (a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.
- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claim 134 is rejected under 35 U.S.C. 102(a) as being anticipated by the article "Geometry Images" by Gu et al., (hereinafter "Gu").

Referring to claim 134, Gu discloses a method of analysis of a geometric surface, the method comprising:

determining a conformal structure of a mesh representation of the surface [p. 355, abstract and section 1]; and

¹ See http://www.uspto.gov/web/offices/pac/dapp/opla/preognotice/section_101_05_15_2008.pdf

using the conformal structure to conformally map the surface representation to a canonical parameter domain [p. 356, section 3].

4. Claims 134, 154, 156 are rejected under 35 U.S.C. 102(a) as being anticipated by the article "Least Squares Conformal Maps for Automatic Texture Atlas Generation" by Levy et al., (hereinafter "Levy").

Referring to claim 134, Levy discloses a method of analysis of a geometric surface, the method comprising:

determining a conformal structure of a mesh representation of the surface [sections 1-A.5, particularly section 2]; and

using the conformal structure to conformally map the surface representation to a canonical parameter domain [sections 1-A.5, particularly section 2].

Referring to claim 154, Levy further discloses determining a period matrix of the surface from the surface representation, wherein the period matrix is a complete invariant of the conformal structure [sections 1-A.5, particularly section A.3].

Referring to claim 156, Levy further discloses that the surface is an open, genus zero surface with a single boundary, referred to as a topological disk, and wherein the canonical parameter domain is a canonical planar disk [sections 1-A.5, also abstract].

Application/Control Number: 10/534,035 Page 5

Art Unit: 2624

5. Claims 134 and 155 are rejected under 35 U.S.C. 102(b) as being anticipated by the article "Conformal Surface Parameterization for Texture Mapping" by Haker et al., (hereinafter "Haker").

Referring to claim 134, Haker discloses a method of analysis of a geometric surface, the method comprising:

determining a conformal structure of a mesh representation of the surface [pp. 181-184, sections 1-3]; and

using the conformal structure to conformally map the surface representation to a canonical parameter domain [pp. 181-184, sections 1-3].

Referring to claim 155, Haker further discloses that the surface is a closed, genus zero surface, and wherein the canonical domain is a sphere [pp. 181-184, sections 1-3].

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claim 135 is rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Gu and Doak et al., U.S. Patent Application No. 2003/0058238 (hereinafter "Doak").

Referring to claim 135, Gu does not explicitly disclose that if the surface is open, transforming a representation corresponding to the open surface into a representation corresponding to a closed surface. However, this feature was exceedingly well known in the art.

Art Unit: 2624

For example, Doak discloses that if the surface is open, a representation corresponding to the open surface is transformed into a representation corresponding to a closed surface [par. 66].

Gu and Doak are combinable because they are both concerned with analyzing geometric surfaces. At the time of the invention, it would have been obvious to a person of ordinary skill in the art to modify Gu in view of Doak. The reason for doing so would have been to enhance the accuracy of the mesh representation of the surface by closing all the opened surfaces. Therefore, it would have been obvious to combine Gu with Doak to obtain the invention as specified in claim 135.

7. Claims 158-159 rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Levy and Krishnamurthy, U.S. Patent No. 6,256,039 (hereinafter "Krishnamurthy").

Referring to claims 158-159, Levy does not explicitly disclose that the canonical parameter domain is a Euclidian plane. However, this feature was exceedingly well known in the art. For example, Krishnamurthy discloses a geometric surface that is mapped to a canonical parameter domain comprising the Euclidian plane [col. 5, 11, 28-36].

Levy and Krishnamurthy are combinable because they are both concerned with analyzing geometric surfaces. At the time of the invention, it would have been obvious to a person of ordinary skill in the art to modify Levy in view of Krishnamurthy. The reason for doing so would have been to enhance the ability to manipulate the mesh representation of the surface [Krishnamurthy, col. 3, ll. 33-35]. Therefore, it would have been obvious to combine Levy with Krishnamurthy to obtain the invention as specified in claims 158-159.

Application/Control Number: 10/534,035 Page 7

Art Unit: 2624

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Charles Kim whose telephone number is 571-272-7421. The examiner can normally be reached on Mon thru Thurs 8:30am to 6pm and alternating Fri 9:30am

to 6pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bhavesh Mehta can be reached on 571-272-7453. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

/CHARLES KIM/ Primary Examiner Art Unit 2624 chongr.kim@uspto.gov

October 8, 2008